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Enhanced adsorption sites in monolayer MoS₂ pyramid structures for highly sensitive and fast hydrogen sensor



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HIGHLIGHTS

 \bullet Enhanced adsorption of $\rm H_2$ gas on monolayer $\rm MoS_2$ pyramids for H2 sensing.

• Least response time, high sensitivity and fast recovery of bare MoS₂ for H₂ sensing.

• High sensitivity of 24% for 0.1% H₂ by monolayer MoS₂ pyramid structures.

• Verification of favourable H₂ adsorption sites by the DFT results reported.

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ABSTRACT

Here, we present a highly sensitive and fast hydrogen (H_2) sensor for 1% H_2 , well below the critical limit of explosion ignite in air, in a temperature range of 28-150 °C by using monolayer MoS₂ pyramid structures with enhanced adsorption sites. The monolayer MoS₂ pyramid structures is synthesized by modified chemical vapor deposition technique and characterized by field emission scanning electron microscopy, Raman, photoluminescence and atomic force microscopy. The highest sensitivity of 69.1% was achieved at a moderate temperature with a response time of 32.9 s for the monolayer MoS₂ pyramid structures. At room temperature (RT), the sensor showed a sensitivity of 6% with a faster response of 11.3 s and recovery time of 125.3 s. The availability of favourable adsorption sites on inplane MoS_2 and edges of MoS_2 in monolayer MoS_2 structures provide enhanced adsorption sites for gas sensing and resulted in the high sensitivity and low response time compared to that of bare MoS₂ and other nanostructures-based H₂ sensor. The detailed gas sensing mechanism is proposed in the light of detail surface morphology and density function theory (DFT). This study reveals that tailoring the favourable adsorption sites in 2D materials is helpful to develop the highly sensitive and fast H₂ sensor for next generation safety devices for H₂ fueled vehicle and clean energy applications.

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Introduction

Recently, hydrogen (H₂) based energy sources emerged as a potential candidate for production of clean and renewable energy, which is considered as the next generation energy source [1]. H₂ energy has been significantly attractive to the worldwide community due to its very high heat combustion (142 kJ/g). Moreover, it also provide independence from limited fossils fuels, and produce clean combustion product compared to those produced by nonrenewable energy sources [2,3]. Nowadays, H₂ gas is broadly used in many areas like chemical, aero-scope, space transportation, oil refining industries and medicine. However, H₂ is extremely explosive and flammable gas if its concentration is greater than 4% over environment volume due to its low ignition energy (0.017 mJ). Hence, a small leakage of the H₂ in any system is very dangerous and detrimental to the safe operation of H₂. Thus, in order to find leakages before a hazardous situation occurs, a highly sensitive, selective, fast recovery and responsive H₂ gas sensor is required.

Over the past few years, semiconducting molybdenum disulfide (MoS₂), a promising member of the transition metal dichalcogenides family has been intensively become the focus of the research community. MoS_2 has exceptional electronic, sensing, optical, catalytic and biological properties [4–6]. MoS_2 consists of the stacked three atoms thick layers bounded by strong covalent bonds and a weak interlayer van der Waals bonds [7]. Bulk MoS_2 has the indirect bandgap of 1.2 eV, which converts to a direct bandgap of 1.8 eV when bulk MoS_2 is thinned down to one layer [7,8]. Due to the higher direct band gap (1.8 eV), faster charge transport, higher surface to volume ratio and higher electron concentration at the surface, MoS_2 has gained tremendous interest for the development of next generation memory devices, solar cells and photodetectors [9–12].

Moreover, MoS_2 has inherent electrical, physical and chemical properties for gas sensing applications [13]. MoS_2 has higher surface-to-volume ratio and an easy way to control adsorption sites in comparison to traditional sensors [14,15]. Recently, the research community has continuously developed H₂, NO₂, NH₃, and H₂S gas sensors based on MoS_2 [16–18]. There are some important parameters like sensitivity, response and recovery time to elucidate the performance of the any gas sensor. The sensitivity is defined as ratio of change in resistance after gas exposure to resistance in presence of air $\frac{R_{gus}-R_{uir}}{R_{uir}}$ × 100% where R_{gas} and R_{air} is the resistance in presence of H₂ and air, respectively. The response time is defined as time required for a sensor to change resistance from 10 to 90% and recovery time is the time required to decay resistance from 90 to 10% of overall change.

However, bare MoS_2 based H_2 gas sensors suffered from long response time, long recovery time and low sensitivity, which is quite impractical for fast detection of H_2 gas [3,19–21]. Moreover, these parameters are enhanced by forming MoS_2 heterostructures with metal nanoparticles, Carbon nanotubes, TiO_2 , reduced graphene (rGO) and graphene [22–28]. These strategies improved sensing performance, but also lead to increase complexity in device manufacturing [28–31]. In a chemiresistive gas sensor, gas molecules interact/ adsorb on the sensing materials and charge transfer takes place between them. This charge transfer induces the change in the electrical resistance of the sensing materials. It has been reported that the gas adsorption is strongly dependent on the particular favourable sites on MoS_2 flakes [22,32,33]. The researchers focused to enhance the favourable adsorption sites of bare MoS_2 by modified growth and orientation of MoS_2 [16,18,34]. However, these in-plane MoS_2 or edgeenriched MoS_2 based sensor either suffered from low sensitivity or higher response and recovery time.

Here, we developed H₂ gas sensor based on monolayer MoS₂ pyramid structures. The height of monolayer MoS₂ pyramids varied from 3 to 25 nm stacked in-plane layers and the top of the pyramids have edge-oriented flakes with a height between 3 and 6 nm. We studied the sensing behavior of sensor down to 1% H_2 gas in the temperature range of 28-150 °C. We observed the highest sensitivity of 69.1% at moderate temperature with a response and recovery time of 32.9 and 141.8 s, respectively. At moderate temperature, sensor also showed a good sensitivity of 24% down to 0.1% of H₂. At RT, the sensor showed significant sensitivity of 6% with fast response and recovery time of 11.3 and 125.3 s, respectively. We proposed that our response time is shorter for a bare MoS₂ based H₂ sensor due to availability of enhanced favourable adsorption sites on in-plane flakes as well as on edges of monolayer MoS₂ pyramid structures. This study revealed that increase in favourable adsorption sites could lead to a fast response and highly sensitive RT H₂ gas sensor.

Experimental section

Synthesis of monolayer MoS₂ pyramids structures

Monolayer MoS₂ pyramids with edge-oriented top flakes fabricated on SiO₂/Si substrate by using modified chemical vapor deposition (CVD) techniques. The sulphur (99.8%, Sigma Aldrich) and MoO₃ (99.8%, Sigma Aldrich) powder were used for the growth of MoS₂ layers. We used the modified three zone chemical vapor deposition technique to grow the monolayer MoS₂ pyramid with edge-oriented top flakes and a small quartz tube closed at one end of the small quartz tube. The small tube was placed inside the big quartz tube in such a way that the close end of the small tube faced in-gas flow. The sulphur powder was placed at the open end in zone 2 and MoO₃ powder was placed in zone 1 at the closed end. The schematic of the experimental setup is shown in Fig. 1(a) and the temperature profile is shown in Fig. 1(b). The growth temperature for the sulphur and MoO₃ powder was 350 °C and 800 °C. The growth time of the deposition was 5 min followed by the natural cooling of CVD. We kept the argon gas flow 175 sccm than slowly decrease up to 100 sccm.

Characterization

The synthesized monolayer MoS₂ pyramids were characterized by field emission scanning electron microscope (FE-SEM), photoluminescence (PL), Raman and atomic force microscopy (AFM). The PL and Raman spectroscopy were performed by



Fig. 1 – (a) Schematic of the modified chemical vapor deposition technique. (b) Temperature profile for the growth of monolayer MoS_2 pyramid structures.

HORIBA iHR 320 spectrometer with a home built optical microscope setup with 532 nm laser at fixed power of ~1 mW and a spot size of 1 μ m. The circular Au/Cr metal contacts of 250/5 nm thick and having diameter 100 μ m with separation of 500 μ m each was deposited by thermal evaporation. The H₂ gas was diluted with Ar gas to test at different concentration in home-build setup. 1% H₂ gas concentration mixed with 99% argon was mixed in a home-built gas setup. The sensing measurements were done by computer controlled 4200 Keithley setup. The biasing voltage was fixed at 4 V during all the sensing measurements by a computer controlled Keithley 4200.

Results & discussion

Structure and morphological study

Fig. 2(a) shows the surface morphology of as-synthesized monolayer MoS_2 pyramid structures. The black region in FE-SEM image shows in-plane monolayer MoS_2 pyramids while white region on top of black pyramid shows edge-oriented MoS_2 flakes [16,18,34]. We further performed close view of completely developed MoS_2 pyramids shown in Fig. 2(b).

Fig. 2(c) shows an individual MoS₂ pyramid where growth of vertically aligned MoS₂ flakes just started. A small hump can be seen clearly in Fig. 2(c) which converts in complete vertically aligned MoS₂ structures with time. Some more FESEM images are added in supplementary information as Fig. S2 for better clarity. Two characteristic Raman peaks are observed at 387.4 and 412.3 cm⁻¹ respectively corresponding to in-plane (E_{2q}^1) and out of plane (A_{1q}) lattice vibrations of MoS_2 as shown in Fig. 2(d). [29, 30] The E_{2q}^1 peak arises due to in-plane vibration of S and Mo atoms in opposite direction, while A_{1q} peak arises due to out of plane vibration of only S atoms, keeping Mo atom at rest. Thus, the peak intensity ratio A_{1g}/E_{2q}^1 can be used to identify the orientation of MoS₂ flakes. The intensity ratio between A_{1g}/E_{2q}^1 is 0.6 and ascertained that most of Raman intensity signals are corresponding to in-plane MoS₂ flakes [34-36]. Fig. 2(e) depicts the photoluminescence spectra of MoS₂ film and showed two prominent peaks at wavelength of 632.7 and 678.0 nm corresponding to B and A band exciton. These two peaks arise due to direct excitonic transfer between conduction band minimum to two split valence bands maximum. The valence band is split due to spin orbit coupling [37]. The crystal structure and phase identification has been done by the XRD. We observed the four sharp XRD peaks (002), (004), (101) and (006) at the 14.09°, 29.10°, 32.5°



Fig. 2 – (a–c) FE-SEM image of monolayer MoS₂ pyramids with edge-oriented top flakes. (d) The Raman spectra of MoS₂ film with two well-known peaks corresponding to E_{2g}^1 and A_{1g} vibrations. (e) PL spectra of MoS₂ film having B and A exciton peaks at 632.71 nm and 678.00 nm. (f) XRD spectra obtained from the film confirming the purity of the grown MoS₂ flakes.

and 44.05°. These peaks are well reported in vertical MOS_2 growth and can be indexed to hexagon phase of MOS_2 [38,39]. The XRD peaks for the MOS_2 further confirmed with JCPDS Card No. 37–1492. The synthesis of the MOS_2 flakes is a twostep process. (i) Reduction of MOO_3 in reduced MOO_2 (ii) Sulphurization of reduced MOO_2 to MOS_2 flakes. The possible chemical reactions are as follows:[34]

$$2MoO_3 + S \rightarrow 2MoO_2 + SO_2 \tag{1}$$

$$MoO_2 + 3S \rightarrow MoS_2 + SO_2 \tag{2}$$

If there is any presence of reduced MoO_3 , it should reflect in XRD. However, we did not observe any peak of reduced MoO_3 . Thus, XRD spectra confirming the pure crystal structure of grown monolayer pyramid MoS_2 flakes.

The schematic of sensor device is shown in Fig. 3(a). When H_2 molecules were exposed to MoS_2 structures, they changed the resistance of the MoS_2 structures. We have studied the IV profile at RT and 150 °C with and without the H_2 exposure, shown in Fig. 3(b–c). We found that I–V curves are linear with and without H_2 exposure. The increase in current due to H_2 exposure is discussed in 3.3. The gas sensing measurements were performed with variable concentration of H_2 at different temperature range of 28 - 150 °C.

Hydrogen gas sensing study

Fig. 4(a) shows sensitivity vs time profile for all temperatures. The sensitivity is higher for higher temperature which implies increased interaction of H₂ gas molecules with monolayer MoS₂ pyramids at higher temperature. It is observed that the resistance decreases with increased H₂ exposure. Fig. 4(b) and (c) shows the response and recovery time of sensor. It can also be seen that lowest response time at RT is 11.3 s. The response time for other temperature ranges from 11.0 to 33.0 s. The calculation for response and recovery time is shown in Fig. 5(a-f) for the RT and at moderate temperature 150 °C. The current vs time graph for the RT and 150 °C is shown in Fig. 5 (a) and (d). It has been observed that the response time is increased with increase in the temperature from 28 to 150 °C. When H₂ gas molecules exposed to sensor, it adsorbed to favourable adsorption sites on the monolayer MoS₂ pyramids with edge oriented top flakes. At RT, the H₂ gas molecules easily adsorbed on the MoS₂ flakes and give response quickly.

However, when the temperature of the device increases, the adsorption of H_2 gas is not so easy due to generated thermal energy. Atoms vibration in MoS_2 increases with increase in the temperature. At elevated temperature, now H_2 gas molecules need time to adsorb on the MoS_2 flakes in comparison to RT. Thus, the response time is also increased.

The nearly constant recovery time of 125–142 s implies that desorption of H₂ molecule is constant throughout all the temperatures. Fig. 4(d) depicts sensitivity profile of sensor. At RT, sensitivity of monolayer MoS₂ pyramids with edgeoriented top flakes is 6%. The sensitivity increased constantly and reached up to maximum sensitivity of 69.1% at 150 °C for 1% H_2 . Higher temperature leads to increased diffusivity of H₂ molecule which increases sensitivity correspondingly In the present study, we studied the H₂ sensing performance from 28 to 150 °C. Kumar et al.; studied the H₂ sensing response from reverse biased MoS₂/GaN heterojunction in the temperature range from 25 to 180 °C [40]. The authors achieved the highest sensitivity at 150 $^\circ\text{C}.$ Beyond 150 °C, the H_2 sensing performance was decreased. The decreased sensitivity was attributed to dominate desorption rate of H₂ gas over the diffusion process. Moreover, in present study, the sensitivity increases from 28 °C to 125 °C rapidly from 6% to 66%. However, at higher temperature from 125 °C to 150 °C, the sensitivity is increase from 66% to 69%. At higher temperature beyond 100 °C, the device showed nearly constant increase in sensitivity. Hence, we study the device sensing behaviour from 28 to 150 °C. Also, our priority was to develop the H₂ sensor at lower temperature and ideally to work at RT. Hence, we study the device sensing behaviour from 28 to 150 °C. We have compared our results with other traditional metal oxides, bare MoS₂, MoS₂ hybrid and metal particle decorated sensor in Table 1. The combination of high sensitivity and low response time for our H₂ sensor at RT and moderate temperature is better than metal oxide nanostructures and any other bare MoS₂ H₂ sensor reported in literatures [41]. Our fabricated device also showed a very low response time in all temperature ranges even at RT compared to other bare MoS_2 based sensors [16,24,30,42,43].

The sensitivity for vertical MoS_2 —Si heterostructure was reported to be ~685%; however, the reported sensor was nearly 10 time slower than our H₂ sensor [43]. The observed response time for monolayer MoS_2 pyramids is even better than our previous H₂ sensor on edge-enriched MoS_2 flakes with enhanced sensitivity at RT and at moderate temperature.



Fig. 3 – (a) Schematic of the gas sensing device. (b) IV curve with and without H_2 exposure at RT and (c) at 150 °C. IV curve clearly showed that the device behaves as the linear and the ohmic behavior with and without H_2 exposure.



Fig. 4 – (a) Sensitivity vs time profile at different temperatures. (b) Response time profile (c) Recovery time profile (d) Sensitivity of monolayer MoS₂ pyramids with edge-oriented top flakes in the temperature range 28–150 °C.



Fig. 5 – Calculation of response time and recovery time at (a–c) RT (d–f) at 150 $^{\circ}$ C for the 1% concentration of H₂ gas.

Hydrogen gas sensing mechanism

To understand the high sensitivity and low response time of our monolayer MoS_2 pyramidal structures, we investigated the detail surface morphology of monolayer MoS_2 pyramids. We did AFM measurements to study surface topography of grown structures. The AFM analysis is shown in Fig. 6(a).

Surface topography of MoS_2 film clearly shows layer by layer growth of monolayer MoS_2 . To gain more insight into the growth, we studied the line profile of grown pyramid MoS_2 flakes and the result is shown in Fig. 6(b). A step like growth pattern is obtained from the line profile. Moreover, we also observed a sudden increase in the line profile at the top of these stacked layer. The number of stacked in-plane layers is 8–30 monolayer with the height of 5–20 nm. Fig. 6(c) shows zoomed area of the line profile. The height of single layer pyramid is around 0.7 nm which implies each stack is monolayer MoS₂ flakes. At the top, growth of edge-oriented MoS₂ takes place which confirmed from sudden increase in height of line profile. The height of edge-oriented flakes is varied from 3 to 7 nm. The surface morphology and step like line profile shown in Fig. 6(a–c) revealed pyramid like growth of MoS₂ structure. The line profile shows that size of individual island varied from 1 to 2 μ m and the uncovered in-plane region on each monolayer pyramid varied from 20 to 30 nm, as shown in Fig. 6(c). Thus, this modified growth method

Table 1 $-$ Summarized literature of different sensing materials based H $_2$ gas sensor.						
S. No.	Materials	T (° C)	Res. Time (sec)	Rec. Time (sec)	S (%)	Ref.
1	Graphene/ZnO composite	100	96.0	190.0	2.0	[24]
2	Vertical MoS ₂ /Si heterojunction	RT	108.7	101.9	685.7	[43]
3	Graphene Palladium	RT	-	600	7	[44]
4	Graphene decorated Pd–Ag nanoparticles	RT	56	-	16.2	[45]
5	Nano-bitter CuO	200	150	1016	175	[46]
6	PdO loaded WO3	RT	126	348	8.02	[47]
7	Pd–Pt/WO3 nanowires	RT	180	240	1.12	[48]
8	GaN	500	22.0	26.0	101.5	[49]
9	Porous MoS ₂ microspheres	120	30.0	60.0	27.5	[23]
10	Edge - Enriched MoS ₂	RT	14.3	136.8	1.0	[16]
11	Pt Functionalized PdO NWs	RT	166	-	62.0	[50]
12	rGO-MoS ₂ nanoparticles	60	15.6	251	260	[51]
13	ZnO Nanowire	250	60	14	98%	[52]
14	SnO ₂ nanowires	300	>100	60	-	[53]
15	TiO ₂	180	131	68	18	[54]
16	In ₂ O ₃	260	1.7	1.5	18	[55]
17	Pt/TiO ₂ /RGO	180	54	48	46	[54]
18	Pd–C core-shell nanoparticles	150	42	23	38	[56]
19	Pd/TiO ₂ /RGO	180	18	29	92	[54]
20	ZnO Single Nanorod	RT	30-40	50-90	4	[57]
21	Monolayer MoS ₂ pyramid	RT	11.3	125.3	6	Present work
22	Monolayer MoS2 pyramid	150	32.9	141.8	69.1	Present work

provides more favourable adsorption sites as well as a higher surface area in monolayer MoS_2 pyramid structures for H_2 molecule interaction. A 3D schematic of monolayer MoS_2 pyramids with edge-oriented top flakes is shown in Fig. 6(d).

The deposition rate, growth rate and sulphur rich environment are the important parameter to grow these special structures. Here, we first create sulphur rich environment in the small tube which plays vital role to synthesize MOS_2 flakes [58]. It is reported that closed end of the tube has very small gas velocity at closed end in comparison to open end of the tube [59]. Thus, MOS_2 vapor formed by the vaporization of the S and MOO_3 powder deposited slowly on the substrate.

Initially, we heat the sulphur powder first to create sulphur rich environment. For the growth of monolayer MoS_2 pyramids, Sulphur and MoO_3 react with each other and form MoS_2 vapors. Vaporized MoS_2 condensed on substrate and form inplane monolayer MoS_2 . With increase in growth time, more incoming MoS_2 vapors start condensing on the substrate and form isolated islands. Incoming atoms/molecules nucleate and formed first, second, third stacked on islands stacked.

Therefore, after a certain critical thickness of in-plane MoS_2 flakes, other factors like strain and screw dislocation may take place in the MoS_2 film. These factors restrict the growth direction in the in-plane. Thus, the growth direction of MoS_2 film changes from in-plane to vertical aligned direction [58]. The islands developed on whole substrate and formed monolayer MoS_2 pyramids with edge-oriented top flakes following the Stranski Krastanov growth model.^{34,60} The growth of monolayer pyramids reveals the stacked monolayer and large number of exposed atomic edges [61]. Hence, with these monolayer pyramids not only the exposed area is increased but also large number of favourable adsorption sites are increased which enhanced H_2 gas adsorption. Therefore, in our case we controlled the surface reaction rate and mass transfer rate by controlling the gas flow [34]. Thus, tube in tube

arrangement provide the slow and controlled sulphurization of the MoS₂ flakes on the substrate and plays an important role to achieve monolayer MoS₂ pyramid structures [58,62].

We proposed H₂ sensing mechanism based on the preferential and enhanced adsorption sites for H₂ of monolayer MoS₂ pyramids. The gas molecules adsorption on MoS₂ is highly position dependent [33]. The gas molecule interaction is examined by adsorption energy and charge transfer between MoS₂ and gas molecules at different sites. It has been well reported theoretically and experimentally that gas molecules adsorption on MoS₂ can be happen on four adsorption sites top of hexagon (H), top of Mo atoms (T_M), top of S atoms (T_s), and top of Mo–S bonds (B) as shown in Fig. 6(d) [63,64]. The adsorption energy calculated by $E_a = E_{MoS_2+molecule}$ - $(E_{MoS_2} + E_{molecule})$. Here, $E_{MoS_2+molecule}$ is total adsorption energy of jointly formed MoS₂ and H₂ gas molecule bonded on it. E_{MoS₂} and $E_{molecule}$ are total energy of individual MoS₂ and H₂ gas molecule, respectively [63]. For favourable adsorption of gas molecule, the adsorption energy should be negative and the reaction is exothermic in nature. The highest negative adsorption energy of a sensing material for a particular gas implies more selective and sensitive nature of the material for that gas. Another important parameter is the electron transfer between gas molecules and MoS2 flakes. If the electron transfers from gas molecule to MoS₂ then gas called as electron donor while if electron transfer from MoS₂ to gas molecule then gas called as electron acceptor. [63], Yue and his coworkers reported that possible adsorption sites on MoS₂ for H₂ gas molecules adsorption are T_M, H and T_S sites with theoretically calculated adsorption energies of -82 meV, -70 meV and -49 meV, respectively [63]. The H sites are highly probable at in-plane MoS₂ flakes while T_M and T_S sites are probable at edge-enriched MoS₂ flakes and on in-plane MoS₂ flakes. In another report by Ganji et al.; H2 gas adsorption studied on MoS_2 and WS_2 flakes [64]. The adsorption energy for H_2



Fig. 6 – (a) AFM surface topography of monolayer MoS_2 pyramids with top edge-enriched flakes. (b) The line profile of as grown MoS_2 pyramids with edge-oriented top flakes. (c) The zoomed line profile which clearly shows thickness of each stacked layers is 0.7 nm correspond to monolayer and uncovered region of monolayers is varied from 20 to 30 nm (d) Schematic of the grown MoS_2 flakes. (e) Possible adsorption sites available on MoS_2 pyramids with edge-oriented top flakes and calculated adsorption energies and charge transfer at respective sites. (f) H_2 gas molecule interaction with MoS_2 pyramids with edge-oriented top flakes. H_2 interact with MoS_2 and takes the electron from MoS_2 .

adsorption on MoS_2 is -131.61 meV at the top of Mo atoms. Moreover, authors found positive 0.004e charge transfer from MoS_2 to H_2 molecules. In our monolayer MoS_2 pyramid structures, we not only enhanced H site on stacked in-plane MoS_2 pyramids but also enhanced T_M and T_S sites on exposed edges simultaneously.

Also, it is clear that combination of these three sites on inplane MoS_2 and edge-enriched MoS_2 in such a large extent is not possible. The stacked in-plane monolayer MoS_2 pyramids increases H sites and exposed edges of in-plane and edgeoriented flakes at top increases T_M and T_S sites [63]. The H₂ gas molecule interaction with MoS_2 pyramids having edgeoriented top flakes is shown in Fig. 6(e). Fig. 6(e) revealed that each stacked in-plane layer not only provides large surface area for H₂ gas interaction but also favourable in-plane and edge sites. The combination of T_M , H and T_S sites available in monolayer MoS_2 pyramids is mainly responsible for high sensitivity, fast response and comparatively low recovery time. Moreover, the net positive electron transfer from MoS_2 to H_2 molecules is 0.004e for both H sites and T_M sites and 0.008e at the T_S site; this also verified that H_2 has an electron acceptor nature for the MoS_2 [63]. The chemical reactions between the MoS_2 and H_2 gas molecules is shown in Fig. 6 (f). Exposed H_2 molecules are interacting with all layers from base to top in monolayer MoS_2 pyramids. The monolayer MoS_2 flakes provided all possible three combinations (H sites, T_S sites and T_M sites) of the favourable adsorption sites require for H_2 gas molecule adsorption. Thus, exposed H_2 gas molecules strongly adsorbed on the MoS_2 flakes. Hence, when H_2 gas turned off, H_2 gas molecules need time to desorbed from the monolayer MoS_2 pyramids. Which leads to high recovery time.

The electron acceptor nature of H_2 gas on MoS_2 flakes is also observed in our previous reports. We fabricated the highly dense vertical aligned MoS_2 flakes [16]. The vertical aligned MoS_2 flakes have the T_M and T_S sites only which is favourable adsorption sites for H_2 adsorption. The vertical aligned MoS_2 flakes showed n-type behaviour and when H_2



Fig. 7 − (a) Cyclability performance of monolayer MoS₂ pyramid structures sensor. (b) Zoomed View of first two cycles of cyclability data. (c) Dynamic plot for different concentrations of H₂ gas at 150 °C.

exposed to vertical aligned MoS₂ flakes, the resistance of the film is increased which also implies that H₂ gas takes electrons from vertical aligned MoS₂ flakes. The possible H₂ adsorption reactions between MoS₂ and H₂ gas molecules are as follows;

$$MoS_2 + H_2 \rightarrow (MoS_2)^+ + (H_2)^-$$
 (3)

In another report, we studied the NO₂ sensing by utilizing the p type mixed MoS₂ flakes [18]. Mixed MoS₂ flakes have the combination of in-plane MoS₂ flakes and vertical aligned MoS₂ flakes. The favourable NO₂ adsorption sites in the mixed MoS₂ flakes are H sites, T_S site and B site. In this case of mixed MoS₂ flakes, we also studied the H₂ sensing performance on the mixed MoS₂ flakes. We again observed similar behaviour with H₂ gas. H₂ and NO₂ both behaves as the electron acceptor and the resistance of the film decreased. However, this time H₂ sensing performance has been decreased due to less availability of favourable adsorption sites in mixed MoS₂ flakes.

It is clear now that H_2 takes electron from MoS_2 film. However, resistance is decreased with H_2 exposure which implies that grown MoS_2 is of p-type in nature. This p -type behaviour can also be seen from IV curve taken at RT and 150 C shown in Fig. 3(b–c). The monolayer MoS_2 flakes with edge oriented top flakes having the p type nature, which implies MoS_2 flakes have the holes as the majority charge carrier while electrons as the minority charge carriers. When H_2 gas exposed to device, H_2 gas molecules withdraw the electron from p type MoS_2 flakes due to its electron acceptor nature. Hence majority of holes carriers increases in p type MoS_2 flakes which decreases the resistance of the films. Thus, the current is increased with H_2 exposure, as can be seen from Fig. 3(b–c).

The p type behaviour of monolayer MoS_2 pyramid structures may be attributed to the various defects and oxygen adsorption on the surface of MoS_2 . In a report by Neal et al. the author predicted that a controlled adsorption of oxygen or interaction with MoS_2 may induce a p type doping. Furthermore, some other factors like defects generated during the synthesis of pyramid MoS_2 by chemical vapor deposition, charge interaction/transfer from the substrate, effect of metal semiconductor contact, annealing results in the controlled p type behaviour of MoS_2 flakes [18,65,66].

Finally, we did the cyclability and dynamic concentrations measurement to check the stability of the H_2 gas sensor.

Cyclability is an important parameter to understand the stability of the chemiresistive gas sensor. The current vs time profile for the 16 cycles at 150 °C is shown in Fig. 7(a–b). We have tested the stability over the span of two months at all temperatures. We have observed that sensitivity is nearly constant for this sensor. The dynamic plot for the different concentrations is shown in Fig. 7(c). The H₂ concentration is varied from the 0.1, 0.3, 0.5, 0.7 and 1%. For the 0.1% H₂ concentration the sensitivity is 24%, which is quite high for such a low concentration of H₂ and shows the high sensitivity of sensor for even very low concentration of H₂.

Conclusion

In conclusion, we synthesized monolayer MoS₂ pyramid structures by modified CVD. Each pyramid consists 3-25 layers of in-plane monolayer MoS₂ flakes while capstone of each pyramid has edge-oriented MoS₂ flakes with a height from 3 to 7 nm. The uncovered region in each stacked layer is around 24–28 nm with size of each pyramid in the range of ~1–2 μ m. The sensitivity of these pyramid MoS₂ flakes is 6% for 1% H₂ with a fast response time of 11.3 s at RT. Furthermore, the gas sensing mechanism based on DFT also confirmed that our proposed modified growth method is responsible for highly sensitive and fast detection of H₂ gas molecules on monolayer MoS₂ pyramids with edge-oriented top flakes. Monolayer MoS₂ pyramids with edge-oriented flakes at top provided highly favourable adsorption sites at top of hexagon (H), top of Mo atoms (T_M) and top of S atoms (T_s). We believe that proposed research work clearly provides more insight to understanding role of favourable adsorption sites to design a highly sensitive and fast H₂ sensor for safe operation of next generation H₂ based fuel systems.

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Appendix A. Supplementary data

Supplementary data to this article can be found online at https://doi.org/10.1016/j.ijhydene.2020.01.119.

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